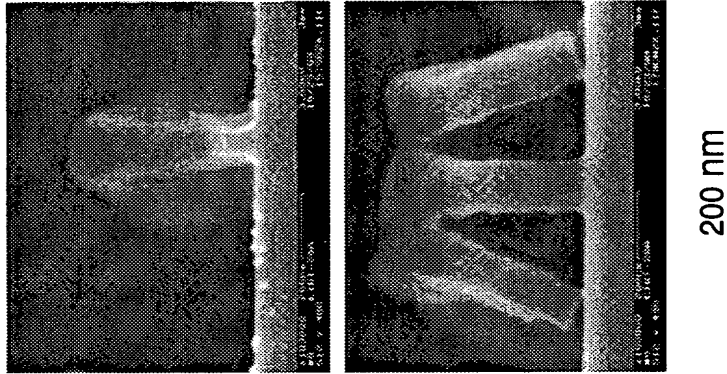
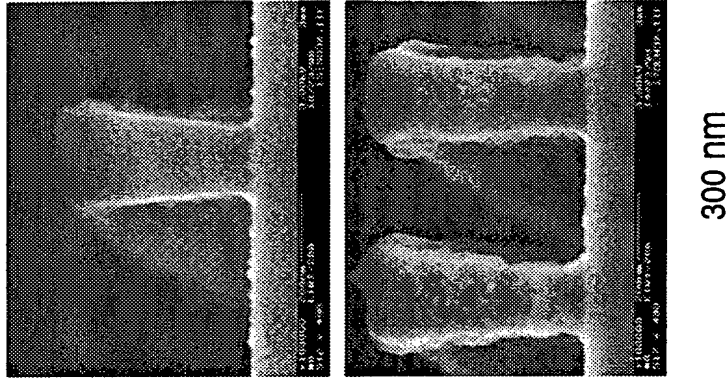


FIG. 1

EXPERIMENTAL 20% SiO₂ EIRT RESIST



UV5 RESIST COMMERCIAL ORGANIC RESIST

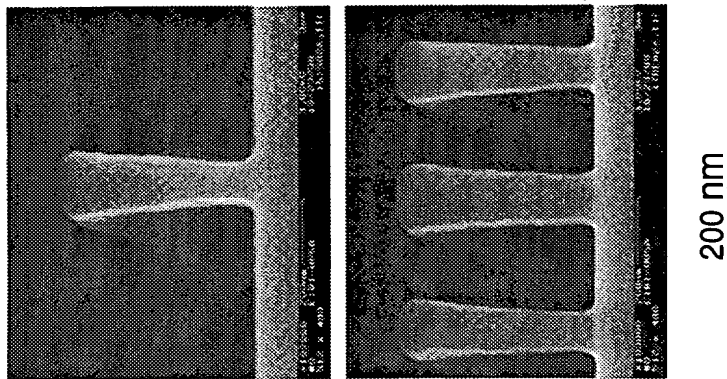
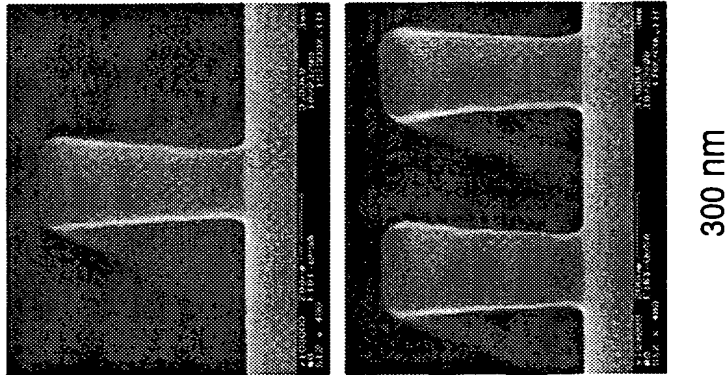


FIG. 2

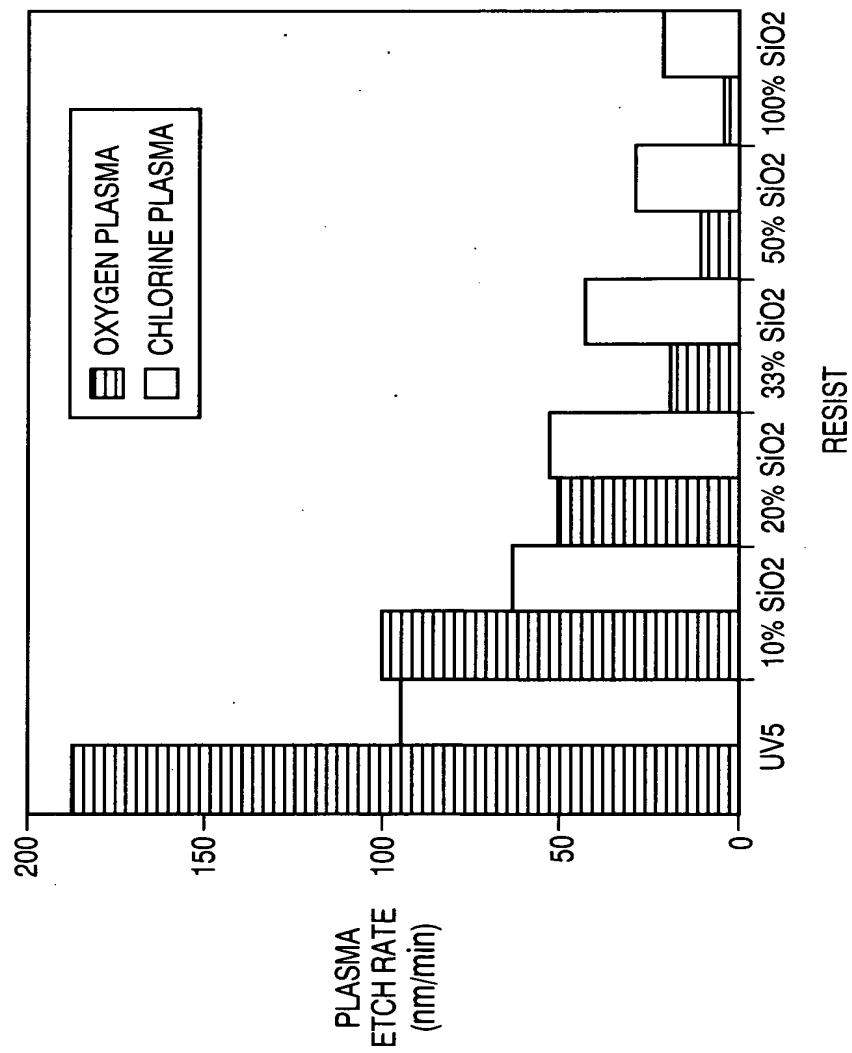
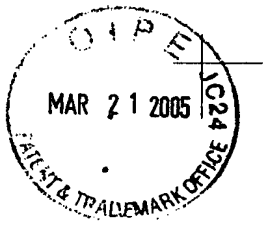


FIG. 3



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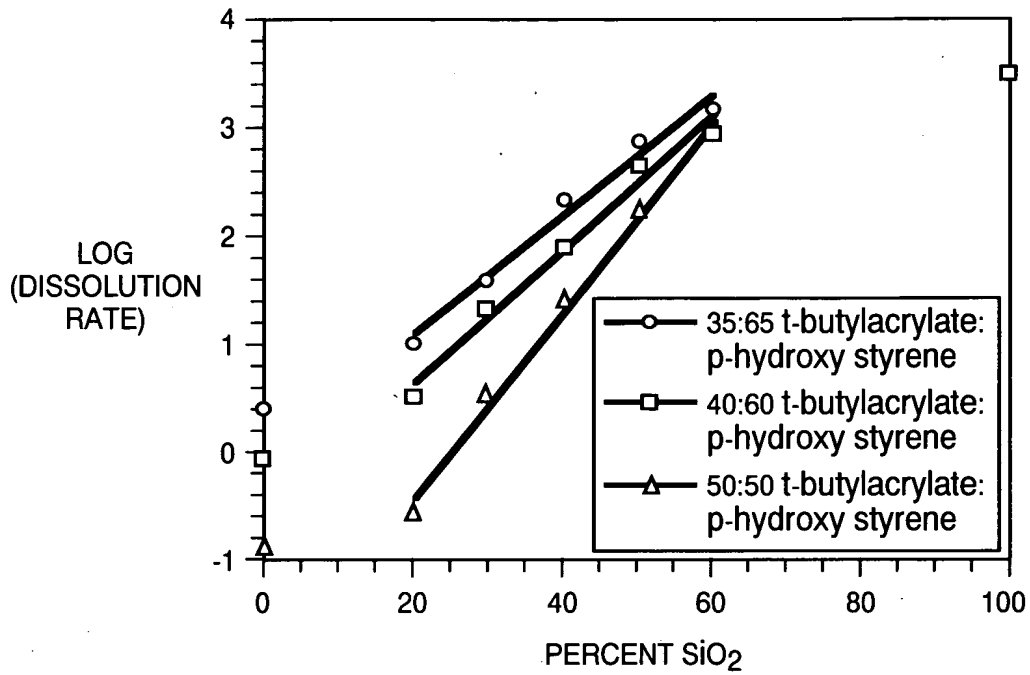


FIG. 4

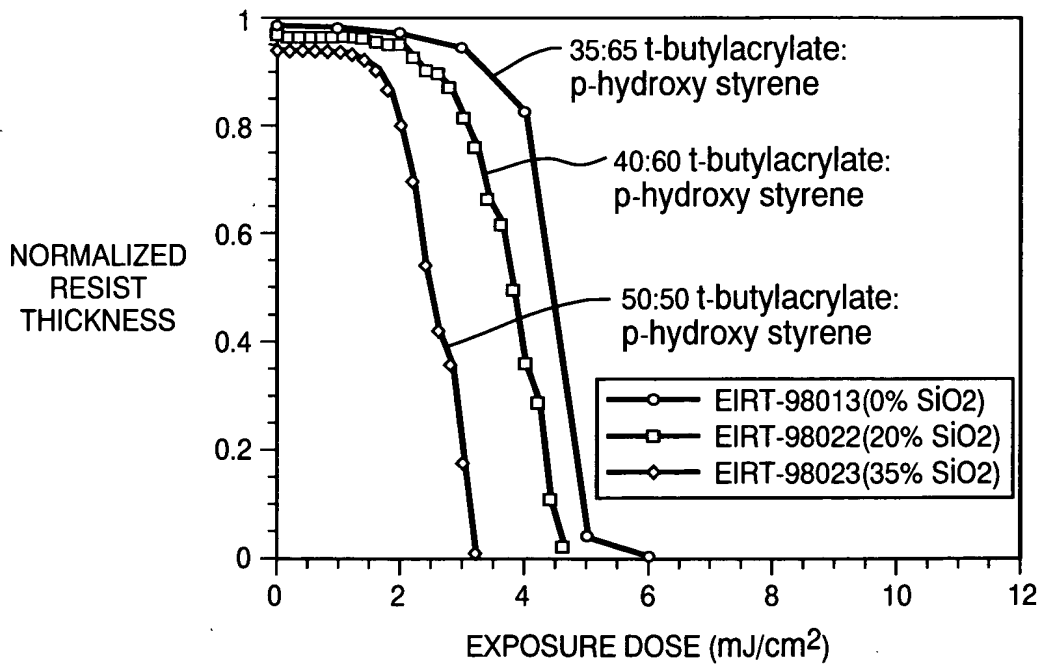
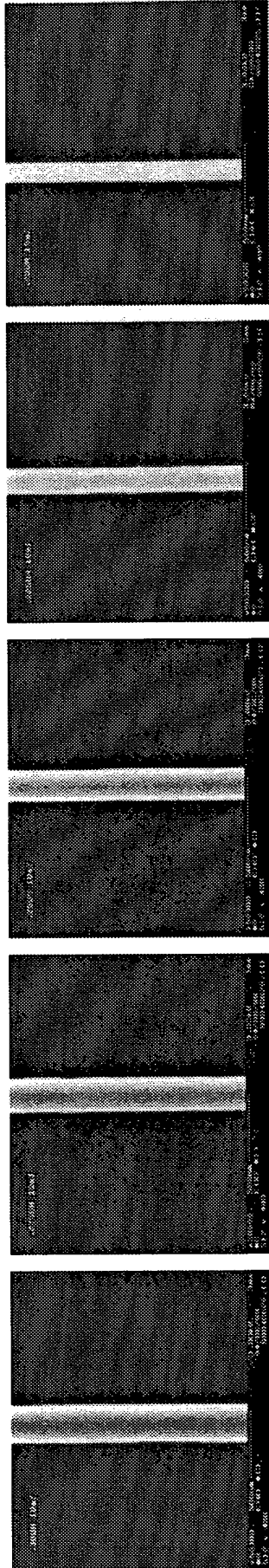


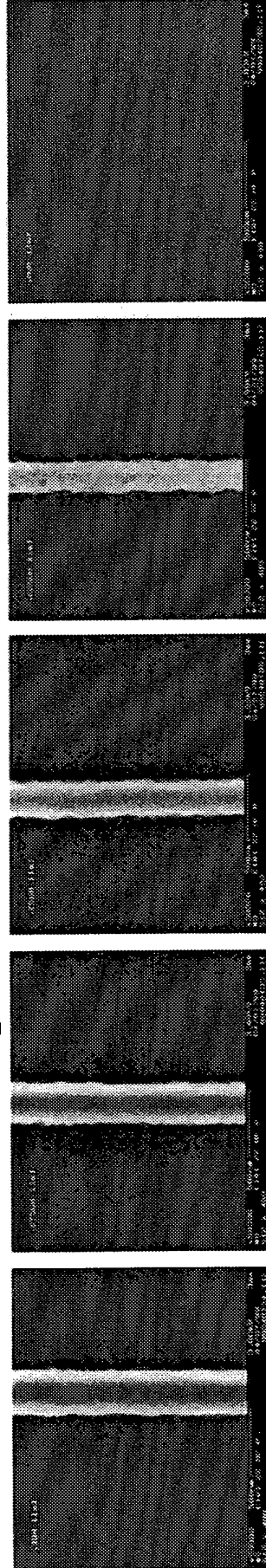
FIG. 5



EIRT 98013 RESIST (0% SiO₂) PREPARED FROM 35:65 T-BUTYLACRYLATE:P-HYDROXYSTYRENE



EIRT 98022 RESIST (20% SiO₂) PREPARED FROM 40:60 T-BUTYLACRYLATE:P-HYDROXYSTYRENE



300 nm 275 nm 250 nm 225 nm 200 nm

FIG. 6